

Notice of References Cited	Application/Control No. 10/061,127	Applicant(s)/Patent Under Reexamination VISCO ET AL.	
	Examiner Kishor Mayekar	Art Unit 1753	Page 1 of 1

U.S. PATENT DOCUMENTS

*		Document Number Country Code-Number-Kind Code	Date MM-YYYY	Name	Classification
*	A	US-5,318,951	06-1994	Shintaku et al.	505/472
*	B	US-6,217,732	04-2001	Schuh et al.	204/490
*	C	US-6,270,642	08-2001	Basu et al.	204/487
*	D	US-6,605,316	08-2003	Visco et al.	427/115
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	I	US-			
	J	US-			
	K	US-			
	L	US-			
	M	US-			

FOREIGN PATENT DOCUMENTS

*		Document Number Country Code-Number-Kind Code	Date MM-YYYY	Country	Name	Classification
	N					
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NON-PATENT DOCUMENTS

*		Include as applicable: Author, Title Date, Publisher, Edition or Volume, Pertinent Pages)
	U	ISHIHARA et al., "Electrophoretic Deposition of Y2O3-Stabilized ZrO2 on the Porous La0.8Sr0.2 MnO3 Cathode Substrate for SOFC", Proceedings of the Fourth International Symposium on Solid Oxide Fuel Cells, 334-343, Electrochemical Soc., Inc., 1995.
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*A copy of this reference is not being furnished with this Office action. (See MPEP § 707.05(a).)
Dates in MM-YYYY format are publication dates. Classifications may be US or foreign.